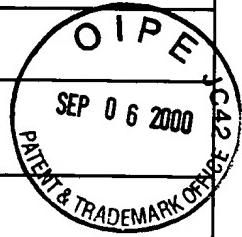


Form PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT & TRADEMARK OFFICE	CASE NO. 761 P7	SERIAL NO. 08/825,360
<b>INFORMATION DISCLOSURE STATEMENT</b> <i>(Use several sheets if necessary)</i>		APPLICANT Liao et al.	FILING DATE March 28, 1997
		GROUP 2814	SEP 06 2000 PTO



## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

**OTHER** (*Including Author, Title, Date, Pertinent Pages, Etc.*)

**EXAMINER**

Kuach

**DATE CONSIDERED**

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Form PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	CASE NO. 761 P3	SERIAL NO. 08/677,185
INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i>		APPLICANT Danek et al. /Iau et al.	08/825360
		FILING DATE 07/09/96 3/28/97	GROUP 1703 2814

## **U.S. PATENT DOCUMENTS**

## **FOREIGN PATENT DOCUMENTS**

**OTHER** (*Including Author, Title, Date, Pertinent Pages, Etc.*)

TU		Park et al. "A Novel A1-Reflow Process Using Surface Modification by the ECR Plasma Treatment and its Application to the 256Mbit DRAM" Semiconductor R&D Center, Samsung Electronics Co. Ltd. pp. 109-112, Dec. 11, 1994  COM

**EXAMINER**

Wm. H. Tracy

**DATE CONSIDERED**

9/22/00

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